

**Amendment to the drawings**

Typographical errors in Figures 5A and 5B were made. In Figure 5A, the reference to “first etchant” in box 504, third line from the bottom was change to “second etchant”. Also, in Figure 5B, the reference to “first etchant” in box 508, fourth line from the bottom was changed to “second etchant”.

The drawing changes are made to correct typographical errors. Support for the changes is present in the patent application as filed, for example, in the discussion in connection with Fig. 4B with regard to the second etchant having a low selectivity with respect to the second hard mask layer 403b. No new matter is added.

Please replace drawing sheet number 12 and 13 as originally filed with the attached same numbered drawings sheets, each sheet marked as REPLACEMENT SHEET.

**REMARKS/ARGUMENTS**

This preliminary amendment is made to correct typographical errors in the specification, claims, abstract, and drawings.

Where references are made to a BARC layer 212, we have corrected this to BARC layer 222. The change is made to correct a typographical error. Fig. 2B shows the BARC layer to be 222, and there are no other structures in the specification with reference number 212.

Where references are made to a trench mask layer 201, we have corrected this to a trench mask layer 202. Fig. 2D shows the trench mask layer to be 202, and there are no other structures in the specification with reference number 201.

The reference at the end of paragraph 66 to step 502 is a typographical error (as can be readily appreciated when read in view of the drawing). That reference has been changed to “step 504”.

The references to “first etchant” as having low selectivity with respect to the second hard mask layer in the summary, specification, claims, and drawings have been corrected to refer to “second etchant” as having the low selectivity with respect to the second hard mask layer. The change is made to correct a typographical error. The second etchant is discussed in connection with Fig. 4B as having a low selectivity with respect to the second hard mask layer (mask 2 403b).

Thus, it is respectfully submitted that these changes do not add any new matter.

The Commissioner is authorized to charge any additional fees to process this Amendment, or credit any over-payments that may apply, to our Deposit Account No. 50-2284 (Order No. LMRX-P032/P1205).

Respectfully submitted,

/Joseph A. Nguyen/  
Joseph A. Nguyen  
Registration No. 37,899

Tel: 408-257-5500